

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	3263	((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS:	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/06/20 18:51
L2	206	1 and (liner near3 nitride) same trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 19:21
S1	2825	((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS:	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/06/20 18:51
S2	495858	(anneal\$3 or heat\$3) near3 (treatment or process or step)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/28 20:48
S3	618	(liner near3 nitride) same trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/06/20 18:56
S4	170	((anneal\$3 or heat\$3) near3 (treatment or process or step)) and ((liner near3 nitride) same trench)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 13:03
S5	68	(((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS:) and (((anneal\$3 or heat\$3) near3 (treatment or process or step)) and ((liner near3 nitride) same trench))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 13:03
S6	10	("5763315" "6037018" "6271153" "6319794" "6323106" "6331469" "6350662" "6391738" "6461937" "6524930" "2002/0070430").PN.	USPAT	OR	OFF	2004/07/25 13:12
S7	0	"6734082":URPN.	USPAT	OR	OFF	2004/07/25 13:14

S8	28	("4571819" "4952524" "5189501" "5190889" "5206182" "5447884" "5521422" "5554256" "5578518" "5677234" "5712185" "5747866" "5750433" "5753562" "5780346" "5801083" "5834358" "5837595" "5837612" "5858842" "5863827" "5872045" "5882982" "5885883" "5940716" "5985735" "6136664" "6251746").PN.	USPAT	OR	OFF	2004/07/25 13:14
S9	3	"6461937".URPN.	USPAT	OR	OFF	2004/07/25 13:17
S10	5	("4571819" "4666556" "5189501" "5897361" "5985735").PN.	USPAT	OR	OFF	2004/07/25 13:18
S11	6	"6326282".URPN.	USPAT	OR	OFF	2004/07/25 13:19
S12	12	("4269654" "4631803" "4700464" "4952524" "5492858" "5516721" "5604159" "5643823" "5719085" "5763315" "5858109" "5933749").PN.	USPAT	OR	OFF	2004/07/25 13:20
S13	11	"6140208".URPN.	USPAT	OR	OFF	2004/07/25 13:21
S14	9	("4631803" "5099304" "5189501" "5190889" "5206182" "5384280" "5387540" "5447884" "5492858").PN.	USPAT	OR	OFF	2004/07/25 13:23
S15	51	"5763315".URPN.	USPAT	OR	OFF	2004/07/25 13:25
S16	51	"5763315".URPN.	USPAT	OR	OFF	2004/07/25 13:28
S17	10	("4417914" "4571819" "4630343" "4630356" "4631803" "4671970" "4692992" "4740480" "4791073" "4824797").PN.	USPAT	OR	OFF	2004/07/25 13:28
S18	19	"5190889".URPN.	USPAT	OR	OFF	2004/07/25 13:29
S19	1	"4907063".PN.	USPAT	OR	OFF	2004/07/25 13:31
S20	20	"5189501".URPN.	USPAT	OR	OFF	2004/07/25 13:31
S21	6	("4104086" "4356211" "4396460" "4404735" "4506434" "4519128").PN.	USPAT	OR	OFF	2004/07/25 13:33
S22	4	("6146974" "6235606" "6326282" "6576530").PN.	USPAT	OR	OFF	2004/07/25 13:34
S23	0	"6727159".URPN.	USPAT	OR	OFF	2004/07/25 13:35

S24	13	("5897361" "6140208" "6146971" "6146974" "6153479" "6165854" "6200881" "6255176" "6255194" "6297128" "6326282" "6331472" "6358796").PN.	USPAT	OR	OFF	2004/07/25 13:35
S25	1	"6426272".URPN.	USPAT	OR	OFF	2004/07/25 13:37
S26	29	("4871689" "4952524" "5189501" "5190889" "5206182" "5447884" "5521422" "5554256" "5578518" "5677234" "5712185" "5747866" "5750433" "5753562" "5801083" "5834358" "5837595" "5837612" "5858842" "5863827" "5872045" "5882982" "5885883" "5940716" "6140208" "6187651" "6251746" "6255176" "6255194").PN.	USPAT	OR	OFF	2004/07/25 13:37
S27	0	"6717231".URPN.	USPAT	OR	OFF	2004/07/25 13:40
S28	10	("5763315" "5940717" "5981356" "5989978" "6146974" "6200881" "6207513" "6255194" "6500726" "6576530" "2002/0003275" "2002/0134754" "2002/0142550" "2003/0143854").PN.	USPAT	OR	OFF	2004/07/25 13:40
S29	0	"6750117".URPN.	USPAT	OR	OFF	2004/07/25 13:42
S30	1	("6461937").PN.	USPAT; USOCR	OR	OFF	2004/07/25 15:19
S31	8912	((nitride near3 oxide) or oxynitride) same trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/28 20:48
S32	7079	((nitride near3 oxide) or oxynitride) same trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:22
S33	495858	(anneal\$3 or heat\$3) near3 (treatment or process or step)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:20

S34	2825	((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2004/07/25 17:20
S35	1647	(((nitride near3 oxide) or oxynitride) same trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:21
S36	279	(((nitride near3 oxide) or oxynitride) same trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))) and (((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:21
S37	2020	((nitride near3 oxide) or oxynitride) near5 trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:23
S38	467	(((nitride near3 oxide) or oxynitride) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:22
S39	125	(((nitride near3 oxide) or oxynitride) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))) and (((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:22
S40	1687	((nitride near3 oxide) or oxynitride) near3 (liner or film or layer) near5 trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:27
S41	407	(((nitride near3 oxide) or oxynitride) near3 (liner or film or layer) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:24

S42	106	((((nitride near3 oxide) or oxynitride) near3 (liner or film or layer) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))) and (((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:24
S43	536	((nitride near oxide) or oxynitride) near3 (liner or film or layer) near5 trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:28
S44	118	((((nitride near oxide) or oxynitride) near3 (liner or film or layer) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:27
S45	28	((((nitride near oxide) or oxynitride) near3 (liner or film or layer) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))) and (((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:28
S46	181	(oxynitride) near3 (liner or film or layer) near5 trench	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:28
S47	53	((oxynitride) near3 (liner or film or layer) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:29
S48	17	((oxynitride) near3 (liner or film or layer) near5 trench) and ((anneal\$3 or heat\$3) near3 (treatment or process or step))) and (((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/07/25 17:29
S49	7	("5447884") or ("5189501") or ("5190889") or ("5206182") or ("5099304") or ("4631803") or ("5384280").PN.	USPAT; USOCR	OR	OFF	2004/07/25 18:45

S50	3077	((438/42) or (438/207) or (438/218) or (438/221) or (438/296) or (438/359) or (438/424) or (438/431) or (438/435)).CCLS.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/28 20:47
S51	875	S50 and (anneal\$3 or heat\$3) near3 (treatment or process or step)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/28 20:48
S52	398	S51 and (((nitride near5 oxide) or oxynitride) same (trench\$2 or groov\$2))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/28 20:49
S53	69	S52 and (((liner near3 nitride) same (trench\$2 or groov\$2)))	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/01/28 20:50